



UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Satoshi MAEMORI et al.

Serial No. 09/955,111

Filed September 19, 2001

: Confirmation No. 9635

: Docket No. 2001_1300A

: Group Art Unit 1752

: Examiner S. LEE

POSITIVE-WORKING PHOTORESIST
COMPOSITION AND PHOTOSENSITIVE
MATERIAL USING SAME

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JUN 23, 2003
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SPW

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of December 19, 2002.

The fee of \$930.00 is

(X) submitted herewith.

() to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.

() Small entity status of this application is established by a Small Entity Status Assertion which
() is enclosed.
() has been previously submitted.

Respectfully submitted,

Satoshi MAEMORI et al.

By Matthew Jacob
Matthew Jacob
Registration No. 25,154
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06/20/2003 AOSMAN1 00000016 09955111

01 FC:1253

930.00 OP

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June 19, 2003